

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 7,109,500 B2  
APPLICATION NO. : 10/509230  
DATED : September 19, 2006  
INVENTOR(S) : Shinji Omori et al.

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

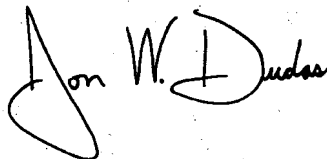
**Title Page:**

Item (54) should be read as follows:

--MASK PATTERN CORRECTION METHOD, PRODUCTION METHOD OF  
SEMICONDUCTOR DEVICE, MASK PRODUCTION METHOD AND MASK--.

Signed and Sealed this

Twenty-ninth Day of May, 2007

A handwritten signature in black ink, appearing to read "Jon W. Dudas". The signature is stylized with a large, looped initial "J" and a cursive "Dudas".

JON W. DUDAS  
*Director of the United States Patent and Trademark Office*